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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/601,701	06/24/2003	Ching-Fa Yeh	BHT-3230-56 7550	
7590 02/10/2006			EXAMINER	
TROXELL LAW OFFICE PLLC			ISAAC, STANETTA D	
SUITE 1404 5205 LEESBURG PIKE			ART UNIT	PAPER NUMBER
FALLS CHURCH, VA 22041			2812	
			DATE MAILED: 02/10/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	an		
Office Action Summary		10/601,701	YEH ET AL.			
		Examiner	Art Unit			
		Stanetta D. Isaac	2812			
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	orrespondence addr	ress		
WHIC - Exter after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DAISIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. O period for reply is specified above, the maximum statutory period we are to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim vill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. nely filed the mailing date of this comr D (35 U.S.C. § 133).			
Status						
1)⊠	Responsive to communication(s) filed on 25 No.	ovember 2005.				
2a) <u></u> ☐	This action is FINAL . 2b) ☐ This action is non-final.					
3)⊠	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.			
Dispositi	ion of Claims					
5)□ 6)⊠	Claim(s) <u>8-14</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdray Claim(s) is/are allowed. Claim(s) <u>8-14</u> is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or	vn from consideration.				
Applicati	ion Papers					
	The specification is objected to by the Examine					
10)⊠	The drawing(s) filed on <u>24 October 2005</u> is/are: Applicant may not request that any objection to the or Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Ex	a)⊠ accepted or b)⊡ objected drawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). jected to. See 37 CFR	1.121(d).		
Priority ι	under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
2) 🔲 Notic 3) 🔲 Inforr	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P	ate	52)		
Pape	r No(s)/Mail Date	6)				

Application/Control Number: 10/601,701

Art Unit: 2812

DETAILED ACTION

This Office Action is in response to the RCE and amendment filed 11/25/05 and 10/24/05, respectively. Currently, claims 8-14 are pending.

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 11/25/05 has been entered.

Specification

The disclosure is objected to because of the following informalities: On page 3, line 5, "oxide 2 formed on" should be "buffer oxide on." In addition, on page 4, line 20, "drain12" should be "drain 12". Appropriate correction is required.

The specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

35 U.S.C. 112, first paragraph, requires the specification to be written in "full, clear, concise, and exact terms." The specification is replete with terms which are not clear, concise and exact. The specification should be revised carefully in order to comply with 35 U.S.C. 112, first paragraph. Examples of some unclear, inexact or verbose terms used in the specification

are: For example, on page 3, lines 6-10, "d) process, a thermal insulating layer of laser annealing or a hard mask of the removal pf polysilicon spacer after recrystallization;" is unclear in its meaning. In addition, on page 3, line 13-15 (see substitute specification filed on 3/03/05), "using a solution of silicon dioxide 6 of wet isotropic etching..." How is this possible? Especially since conventionally wet etching techniques may be used to etch silicon dioxide. Finally, on page 3, lines 11-15 "d) depositing a low temperature oxide 4 on the amorphous silicon film dry etching after step d), and a thermal insulating layer for laser annealing of a hard mask preventing removing of a polysilicon spacer after recrystallization (step f); "is unclear in the meaning.

In general, the Examiner takes to position that the newly revised specifications, still lacks clarity with regards to the disclosure of the claimed invention, in addition, includes numerous grammar and spelling errors.

Claim Objections

Claim 8 is objected to because of the following informalities: On line 22, "and a thermal insulating layer" should read as "a thermal insulating layer," Appropriate correction is required.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 8-14 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

It is indefinite whether the "polysilicon spacer", is formed by the second amorphous silicon film, or by an additional polysilicon layer.

Allowable Subject Matter

Claims 8-14 would be allowable if rewritten or amended to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action.

The following is an examiner's statement of reasons for allowance:

The closest prior art of record, Kato et al., US Patent 5,589,406 in view of Hasegawa Patent Application Publication US 2004/00026738, fails to show, forming a polysilicon spacer on either side of the dog-bone shaped portion of the active layer by, first dry etching the second amorphous silicon film on the active layer and recrystallizing the second amorphous film to form a polysilicon spacer. In addition, by recrystallizing the second amorphous film, large silicon grain structures in the active layer are formed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

This application is in condition for allowance except for the following formal matters:

the specification is objected to regarding numerous grammatical and punctuation errors, as well as, rejected under 35 U.S.C. 112, first paragraph. In addition, the above claim objection, involve grammatical issues. Finally, claims 8-14 are rejected under 35 U.S.C. 112 2nd.

Prosecution on the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

A shortened statutory period for reply to this action is set to expire **TWO MONTHS** from the mailing date of this letter.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stanetta D. Isaac whose telephone number is 571-272-1671. The examiner can normally be reached on Monday-Friday 9:30am -6:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SUPERVISORY PATENT EXAMINER

Stanetta Isaac Patent Examiner January 30, 2006